

Extensive Characterisation of Copper-clad plates, bonded by the Explosive Technique;

for ITER Electrical Joints

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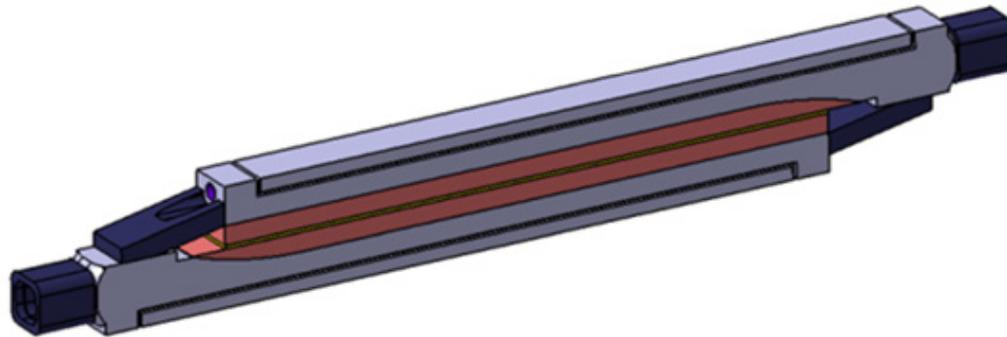


Figure 1: Twin-box shaking hands concept used for ITER electrical joints
G. Rolando et al., *Supercond. Sci. Technol.*, vol. 26, no. 8, p. 085004, Jun. 2013.

Design of the various ITER magnet systems imposes the use of highly performing electrical joints to connect unit lengths of superconducting coils.

Twin-box lap type joints are produced by compacting each cable end into a copper – stainless steel bimetallic box.

To validate technical joint solutions for the various magnet systems, an extensive characterisation is conducted to assess the performance of numerous copper-clad plates.



Figure 2: Cross-cut of a twin-box joint, demonstrating the employed bimetallic solution.

Table 1: Material characteristics of the “As-received” sample blocks

	Sample designation	Sample dimensions		Explosion welding Company	Producer Cu base plate	Material	
		SS [mm]	Cu [mm]			SS	Cu
Plate_1	p1	65	14	Company B	Supplier A	316L	C10100 ^a
Plate_2	p2	90	20	Company B	Supplier A	316L	C10100
Plate_3	p3	33	12	Company C	Supplier D	316L	C10200 ^b
Plate_4	p4	40	12	Company E	Supplier F	316L	C12200 ^c

^aOFE Cu; oxygen-free, electronic copper

^bOF Cu; oxygen-free copper

^cDHP Cu; phosphorized, high residual phosphorus copper

Bimetallic samples issued from various copper to stainless-steel explosion bonded plates were made available for;

- Non-destructive examination
- Microstructural characterisation
- Mechanical properties
- Thermo-electrical properties

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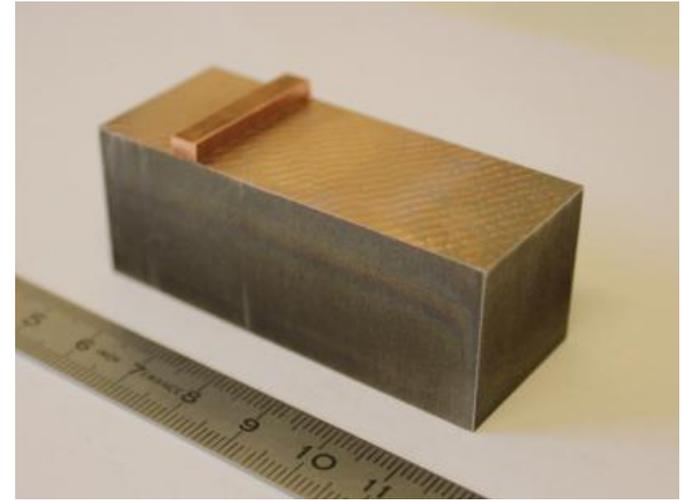
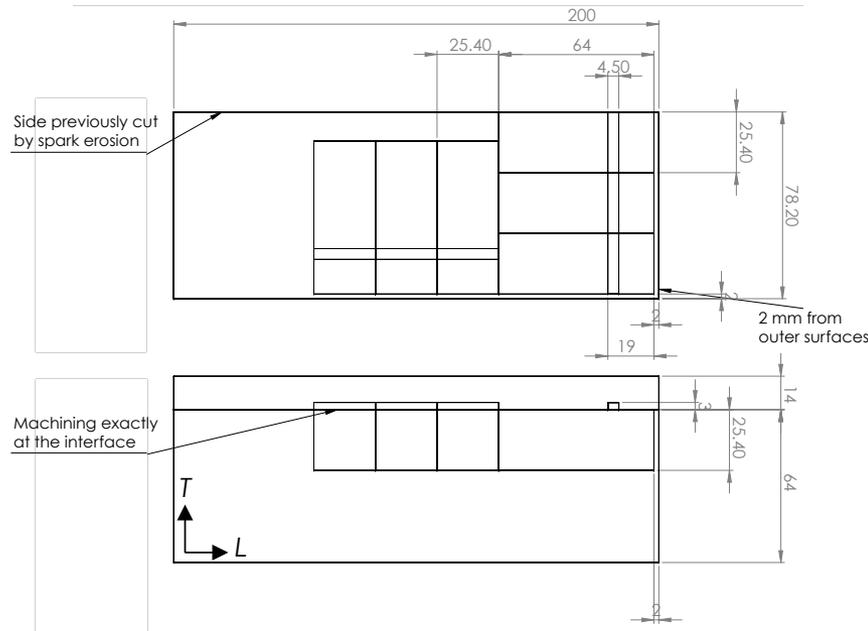


Figure 3: Shear specimen extraction; extraction scheme (left), and machined specimens (right). Machined carefully for shear measurement at the interface

- Shear specimens oriented in transverse as well as longitudinal direction
- carefully machined to ensure measurement of shear characteristics specifically at the interface.

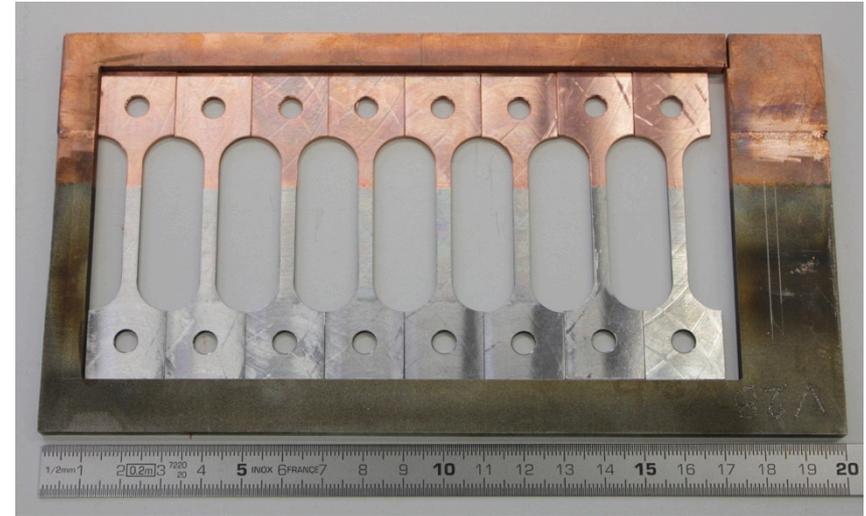
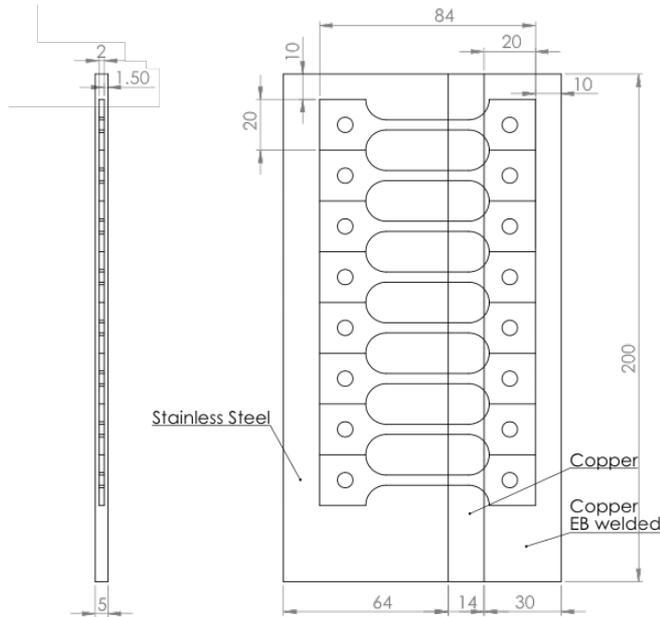


Figure 4: Tensile specimen extraction; extraction scheme (left), and machined specimens (right). Placement of the EB-weld in the larger portion of the head.

- Tensile specimens with longitudinal axis perpendicular to explosion bonded plane.
- Initial by spark-erosion machined slice Electron Beam (EB) welded to additional C10100 Cu strip.
 - To ensure positioning of the interface in the gauge length
 - Placement of EB-weld in larger portion of the head

Table 2: Summary of explosion weld test results including mechanical properties at ambient and cryogenic temperature

	Temp. [K]	$R_{p0.2}^a$ [MPa]	R_m^b [MPa]	$\tau_{max.}^c LD(TD)$ [MPa]
Plate_1	293	259 ± 3	261 ± 2	$269 \pm 24 (317 \pm 15)$
	4.2	311 ± 7	453 ± 6	
Plate_2	293	239 ± 4	251 ± 1	$378 \pm 14 (294 \pm 1)$
	4.2	278 ± 12	459 ± 9	

^a0.2% Yield strength

^bMaximum tensile strength

^cMaximum shear strength

- High average maximum shear values are obtained
- Results are largely subject to the interlocked state at the sheared boundary

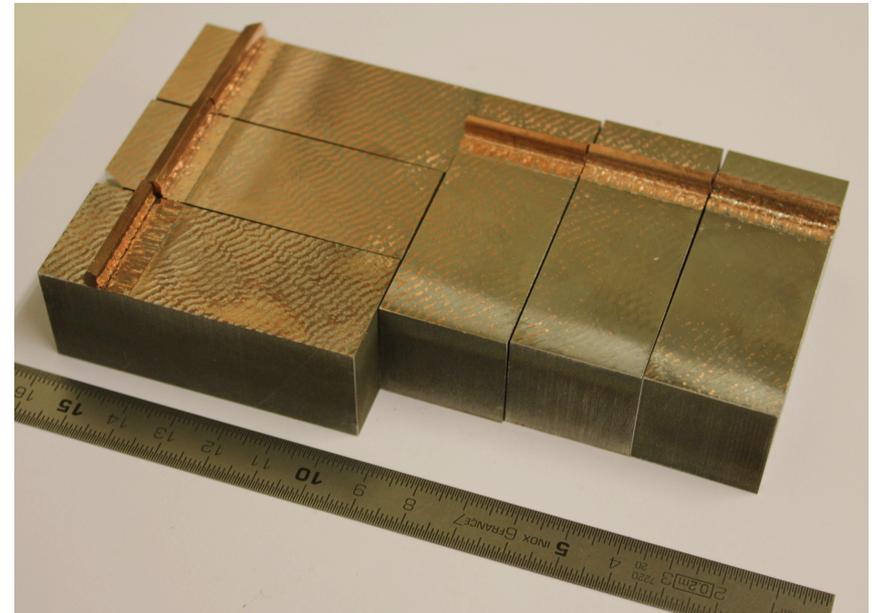


Figure 5: Specimens tested for plate_1, in shear, in longitudinal (left) and transverse direction (right).

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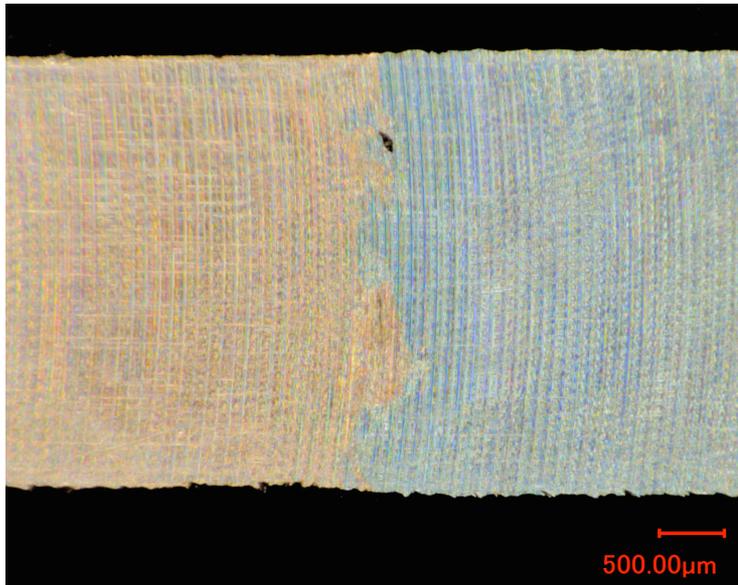


Figure 6: Bonded interface of tensile specimen 4.2 K_2 (plate_2) prior to measurement.

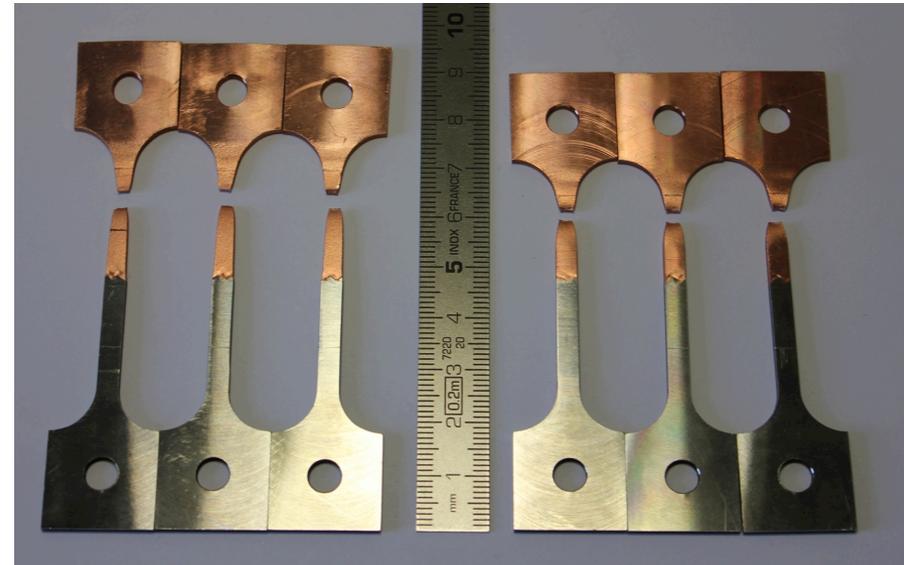


Figure 7: Specimens tested for plate_2, in tension, at 4.2 K (left) and 293 K (right). Failure consistently takes place in the copper cladding

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Room temperature results are consistent with C10100 values in the H02 temper (Hardesty, 1980).

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Table 3: Summary of resistivity vs. hardness results for plate_1 and plate_2

		Distance from interface	HV10	HRF ^a	RRR
Plate_1	Top	at 11 mm	86	78	154
	Bottom	at 5 mm	96	84	116
Plate_2	Top	at 17 mm	85	77	191
	Middle	at 11 mm	94	83	146
	Bottom	at 5 mm	99	86	126

T_{warm} [K] = 293.0
 T_{cold} [K] = 4.5

^aF-scale Rockwell Hardness (HRF) values are converted from the collected Vickers Hardness (HV) data following ASTM E-140

Macro-hardness measurements on the metallographic specimen, performed in the region of failure for the tensile tests, confirmed the H02 temper.

The Residual Resistivity Ratio (RRR) results, obtained in 2-3 positions show decreased values in the vicinity of the bonded interface where the plastic deformation during the explosion bonding process is largest.

This finding is consistent with the obtained results during hardness measurements, which are inversely linked.

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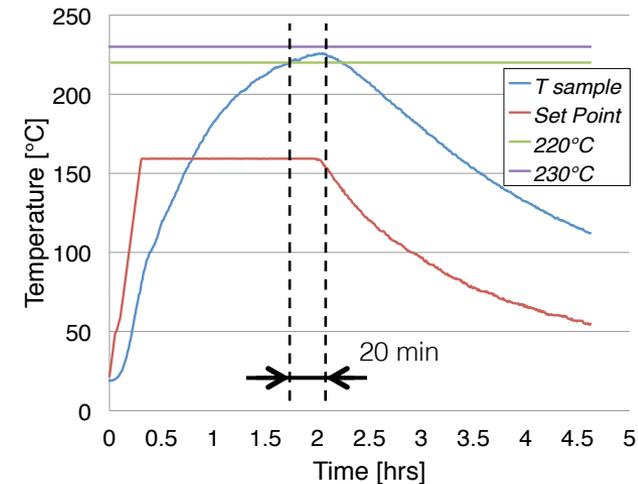
Heat-treatments; simulating final joint formation

Vacuum furnace heat-treatment at low T to simulate the soldering cycle of the terminals for joint formation.

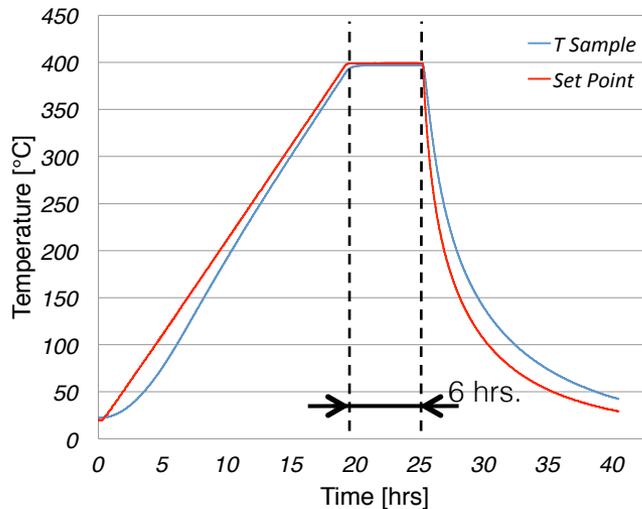
Ramp-up to 230°C over 1.5 hours to simulate heating in 8 steps during the soldering procedure where heating power is maintained at every step until joint temperature is stabilized.

Temperature hold at 230±10°C for 20 min (threshold T = 220°C).

Thermal treatment 20 min @ 230°C



Thermal treatment 6 hrs. @ 400°C



Additional vacuum furnace heat-treatment at high T to simulate optional end heat-treatment of terminal box prior to cable insertion (for copper softening).

Ramp-up rate: 20°C/hr.

Temperature hold at 400°C for 6 hrs. (samples in tube to avoid exposure to direct radiation).

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Vacuum furnace heat-treatment at low T to simulate the soldering cycle of the terminals for joint formation.

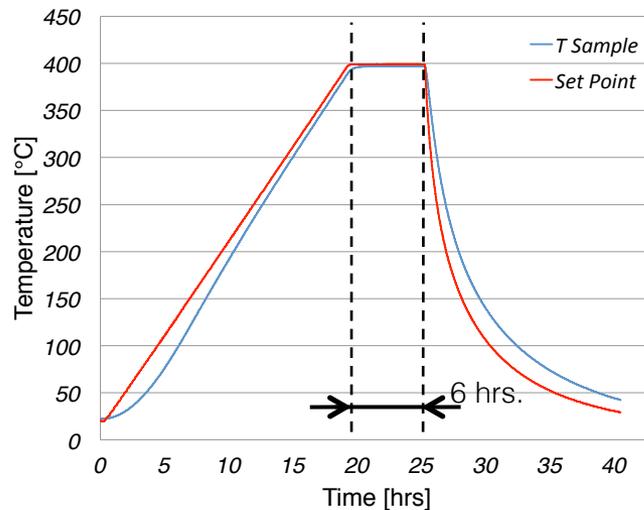
Ramp-up to 230°C over 1.5 hours to simulate heating in 8 steps during the soldering procedure where heating power is maintained at every step until joint temperature is stabilized.

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Figure 8: RRR and hardness specimens positioned for initial heat treatment at 230°C for 20 min.

Thermal treatment 6 hrs. @ 400°C



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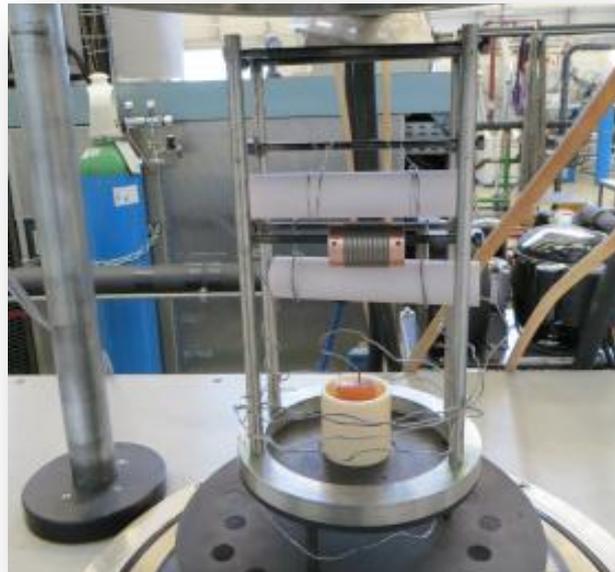


Figure 9: RRR and hardness specimens positioned for additional heat treatment at 400°C for 6 hrs.

Additional vacuum furnace heat-treatment at high T to simulate optional end heat-treatment of terminal box prior to cable insertion (for copper softening).

Ramp-up rate: 20°C/hr.

Temperature hold at 400°C for 6 hrs. (samples in tube to avoid exposure to direct radiation).

Table 3: Summary of resistivity vs. hardness results for the examined plates prior and subsequent to heat-treatments, simulating final joint formation

	Distance from interface	Copper purity	State	HV10	HRF	RRR
Plate_1	Top	C10100	As-bonded	86	78	154
			20 min at 230°C	86	78	176
			6 h at 400°C	42	30	524
	Bottom	C10100	As-bonded	96	84	116
			20 min at 230 °C	98	85	134
			6 h at 400 °C	43	32	474
		C10100 Certified plate (coiled ^a ; 14 mm)		45	35	345
Plate_2	Top	C10100	As-bonded	85	77	191
	Middle	C10100	As-bonded	94	83	146
	Bottom	C10100	As-bonded	99	86	126
			C10100 Certified plate (coiled; 20 mm)		40	29
Plate_3	Top	C10200	Annealed	46	36	95
Plate_4	Top	C12200	As-bonded	113	92	4.8
			20 min at 230 °C	112	92	4.8
			6 h at 400 °C	55	48	5.3
	Bottom	C12200	As-bonded	123	96	4.7
			20 min at 230 °C	117	94	4.8
			6 h at 400 °C	53	46	5.3

C10100, OFE copper explosion bonded to 316L stainless steel;

- Heat-treatment simulating soldering showed no significant effect on the hardness, while a small effect on the RRR is observed.
- In contrary; the subsequent softening cycle fully annealed the copper cladding beyond the initial state, prior to explosion bonding.

^aSubsequent to production, the material is stored on a spool. The deformation results in additional hardening of the material.

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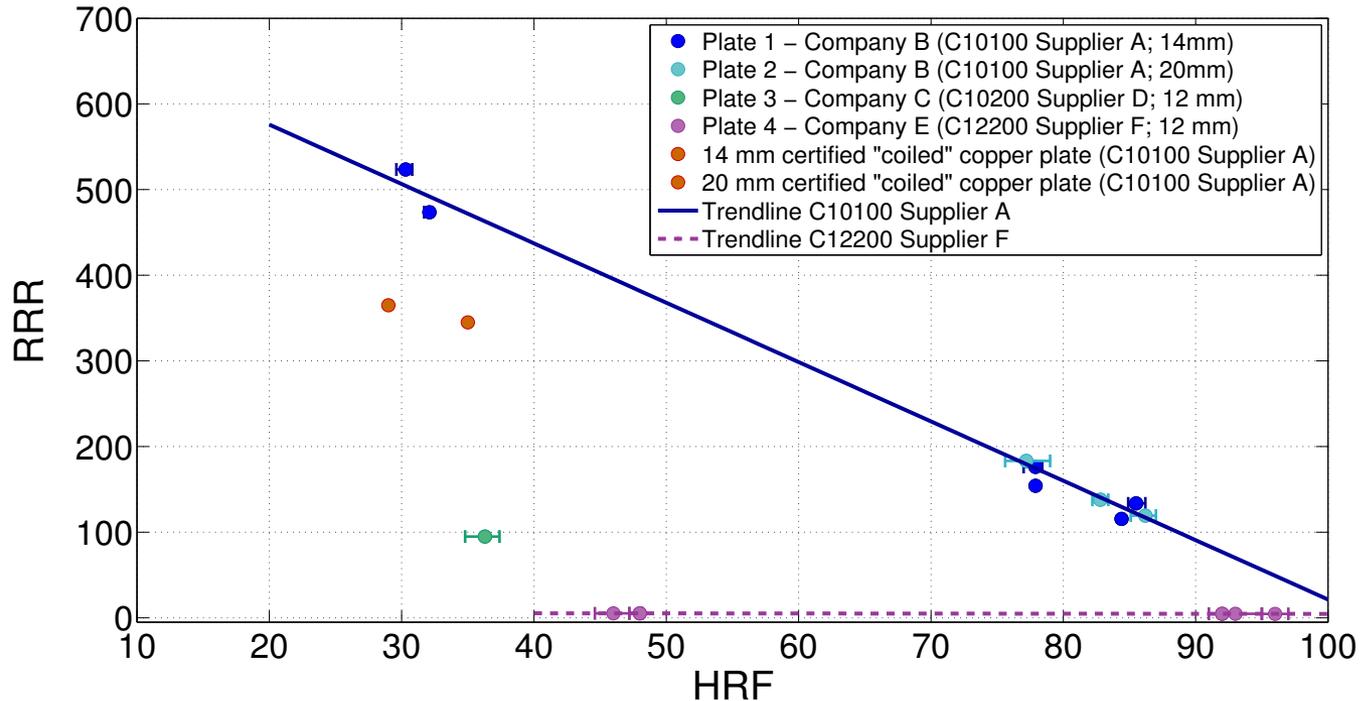
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	Bottom	C12200	As-bonded	123	96	4.7
			20 min at 230 °C	117	94	4.8
			6 h at 400 °C	53	46	5.3

C12200, DHP copper explosion bonded to 316L stainless steel;

- Heat-treatment simulating soldering showed no significant effect on both hardness as well as RRR.
- In contrary; the subsequent softening cycle annealed the C12200 Cu cladding.
- For this low purity grade Cu, RRR is mainly driven by impurity content. No significant increase of RRR is noticed with material annealing by a severe thermal cycle, while a large decrease in hardness is observed.

^aSubsequent to production, the material is stored on a spool. The deformation results in additional hardening of the material.

RRR as function of HRF for the examined copper claddings



- Consistent trend-line for the highly pure C10100 copper, as used in p1 and p2.
- Indication of a slightly less pure C10200 copper in clad plate p3.
- As expected, the purity of the copper as used in p4, C12200, lies beneath the previously mentioned, and shows no noticeable dependence of RRR on hardness.

- An **extensive characterisation** is carried out on a diverse set of copper-clad plates for the electrical joints of the ITER magnet system
- The properties of the examined clad plates are **dominated by the individual materials**
- Increased hardening, **beyond H02**, towards the bonded interface
- **Little effect of the terminal soldering process** on the RRR and mechanical characteristics of both high purity, C10100, as well as low purity, C12200, copper grade claddings
- **High purity C10100**; A high RRR, low hardness, fully annealed state, beyond the initial state of the coiled copper plate, with final softening treatment
- **Low purity C12200**; RRR values are driven mainly by impurity content. No significant increase in RRR with material annealing, solely a large decrease in hardness
- For an electrical joint, connecting unit lengths of coils working in a **pulsed regime**, the use of a **lower purity copper cladding** could be a compromise

